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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: SCHAUER ET AL 1 PCT

SERIAL NO.: 09/890,656 EXAMINER: T.F. TRAN

FILED: AUGUST 2, 2001 GROUP: 2811

TITLE: SEMICONDUCTOR WAFER COMPRISING A THIN EPITAXIAL SILICON LAYER AND METHOD FOR PRODUCING THE SAME

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MAIL STOP NON-FEE AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Non-Final Office Action, dated March 3, 2004, please amend the above-identified patent application as follows:

Amendments to the Specification begin on Page 2 of this document.

Amendments to the Claims begin on Page 3 of this document.

Remarks begin on Page 5 of this document.